

EAST Search History

Ref #	Hits	Search Query	Dbs	Default Operator	Plurals	Time Stamp
L1	2	"7156962"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 17:54
L2	1	"10344368"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 17:59
L3	1	((immers\$3) and (substrate) and (oxidiz\$3 with solution) and (active near2 oxidiz\$3) and (chemical near2 oxide) and (different near3 concentration) and (low-concentration) and (high-concentration) and (azeotropic near2 concentration)).dlm.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 18:26
L4	1	((immers\$3) and (substrate) and (oxidiz\$3 with solution) and (active near2 oxidiz\$3) and (chemical near2 oxide) and (different near3 concentration) and (low-concentration) and (high-concentration) and (azeotropic near2 concentration))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 18:27
L5	1	((immers\$3) and (substrate) and (oxidiz\$3 with solution) and (active near2 oxidiz\$3) and (oxide) and (different near3 concentration) and (low-concentration) and (high-concentration) and (azeotropic near2 concentration))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 18:27
L6	5328	(chemical near oxide)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 18:28

L7	807	(chemical near oxide) with (substrate)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 18:28
L8	568649	(oxidiz\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 18:29
L9	369	7 and 8	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 18:29
L10	240	9 and (concentration)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 18:29
L11	71	10 and ((high-concentration) (high near concentration))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 18:30
L12	50	11 and @ad<="20060815"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 18:34
L13	684	((chemical natura\$3) near (oxide)) with (substrate) with (solution aqueous water wet)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 19:17
L14	51	((chemical natura\$3) near (oxide)) with (substrate) with (solution aqueous water wet) with (immers\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 19:17
L15	46	14 and @ad<="20060815"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 19:17

L16	6095	(oxidiz\$3 with concentration) with (solution)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 19:32
L17	293	(substrate) with (oxidiz\$3 with concentration) with (solution)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 19:32
L18	270	17 and @ad<="20060815"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 19:32
L19	4	18 and (chemical near2 oxide)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 19:33
L20	142	18 and (oxide)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 19:34
L21	142	20 and @ad<="20060815"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 19:34
L22	3	21 and (azeotropic)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/10 19:41
S1	11168	(method) with (semiconductor near package)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/12/19 19:03
S2	18	(clearances) with (grid near2 plane)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/12/19 19:04

S4	2	*7005697*.pn.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/12/24 11:59
S5	2394	((high near dielectric) (high-dielectric)) near (constant) with (improv\$3 provid\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/12/24 12:11
S6	272	S5 and ("al.sub.2o.sub.3")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/12/24 12:12
S7	23	S6 and (hfsion)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/12/24 12:13
S8	1	S4 and (silicide salicide)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/12/24 12:19
S9	2	*6897514*.pn.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/12/24 12:21
S10	1	S9 and (silicide salicide)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/12/24 12:21
S11	1	S10 and amorphous	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/12/24 12:24

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